

**Amendments to the Claims:**

Claim 16. (Currently Amended) A semiconductor laser device with a spot-size converter comprising:

- a semiconductor substrate;
- a semiconductor laser region, and
- a semiconductor layer;

the semiconductor laser region and the semiconductor layer being integrally formed as one unit on the semiconductor substrate in a lateral direction to emit light from the side of the semiconductor layer;

[wherein] the semiconductor layer has a function of changing the spot-size in a layer direction of light emitting from a semiconductor laser by changing a refractive index of the semiconductor layer in the layer direction[.];

wherein the semiconductor layer is a graded index to gradually change a refractive index thereof in a layer direction.

Cancel claim 17.

Claim 18. (Currently Amended) The semiconductor laser device with a spot-size converter according to claim [17] 16, wherein at a time of passing light emitting from the semiconductor laser region through the semiconductor layer, the spot-size of light is periodically changed or shows a behavior of a portion of the periodical changing.

Claim 19. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 16, wherein the most highest region of

refractive index of the semiconductor layer is one conformed with an approximate central portion of a distribution of light emitting from the semiconductor laser region.

Cancel claim 20.

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Claim 21. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 18, wherein the most highest region of refractive index of the semiconductor layer is one conformed with an approximate central portion of a distribution of light emitting from the semiconductor laser region.

Claim 22. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 16, wherein on the boundary between the semiconductor layer and the semiconductor laser region, a second semiconductor layer having a substantially constant refractive index is formed.

Cancel claim 23.

Claim 24. (Previously Amended) The semiconductor laser device with a spot-size converter according to claim 18, wherein on the boundary between the semiconductor layer and the semiconductor laser region, a second semiconductor layer having a substantially constant refractive index is formed.

Claim 25. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 19, wherein on the boundary between

the semiconductor layer and the semiconductor laser region, a second semiconductor layer having a substantially constant refractive index is formed.

Claim 26. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 16, wherein on the boundary between the semiconductor layer and the semiconductor laser region, a dielectric layer is formed.

Cancel claim 27.

Claim 28. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 18, wherein on the boundary between the semiconductor layer and the semiconductor laser region, a dielectric layer is formed.

Claim 29. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 19, wherein on the boundary between the semiconductor layer and the semiconductor laser region, a dielectric layer is formed.

Cancel claim 30.

Claim 31. (Currently Amended) A semiconductor laser device with a spot-size converter comprising:

- a semiconductor substrate;
- a semiconductor laser region;
- a light waveguide region;

the semiconductor laser region and the light waveguide region being integrally formed as one unit on the semiconductor substrate in a lateral direction to emit light from the light waveguide region;

[wherein] at a joint region between the semiconductor laser region and the light waveguide region, a semiconductor layer is buried therein;

wherein the semiconductor layer has a refractive index which is substantially constant.

Cancel claim 32.

Claim 33. (Currently Amended) The semiconductor laser device with a spot-size converter according to claim 31, wherein the semiconductor layer has a refractive index which is changed continuously in a layer direction or varied step wisely.

Claim 34. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 31, wherein the most highest region of refractive index of the semiconductor layer is one conformed with an approximate central portion of a distribution of light emitting from the semiconductor laser region, and with an approximate central portion of an intrinsic mode of the light waveguide region.

Claim 35. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 31, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the

boundary between the semiconductor layer and the light waveguide region, another semiconductor layer having a refractive index which is substantially constant is formed.

Claim 36. (Currently Amended) The semiconductor laser device with a spot-size converter according to claim [32] 31, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, another semiconductor layer having a refractive index which is substantially constant is formed.

✓ Claim 37. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 33, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, another semiconductor layer having a refractive index which is substantially constant is formed.

Claim 38. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 34, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, another semiconductor layer having a refractive index which is substantially constant is formed.

Claim 39. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 31, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, a dielectric layer is formed.

Claim 40. (Currently Amended) The semiconductor laser device with a spot-size converter according to claim [32] 31, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, a dielectric layer is formed.

Claim 41. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 33, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, a dielectric layer is formed.

Claim 42. (Previously Added) The semiconductor laser device with a spot-size converter according to claim 34, wherein on the boundary between the semiconductor layer and the semiconductor laser region and/or the boundary between the semiconductor layer and the light waveguide region, a dielectric layer is formed.

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